

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of

Park, Jong Jin et. al.

Application No.:

Filing Date: April 1, 2004

Group Art Unit:

Examiner:

Confirmation No.:

Title: Photosensitive Semiconductor Nanocrystals, Photosensitive Composition Comprising Semiconductor Nanocrystals and Method for Forming Semiconductor Nanocrystal Pattern Using the Same

22858 U.S. PTO  
10/814264  
040104

**GENERAL AUTHORIZATION FOR PETITIONS  
FOR EXTENSIONS OF TIME AND PAYMENT OF FEES**

Assistant Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

In accordance with 37 C.F.R. §1.136(a)(3), the U.S. Patent and Trademark Office is hereby provided with a general authorization to treat any concurrent or future reply requiring a petition for an extension of time for its timely submission as containing a request therefor for the appropriate length of time.

The Commissioner is hereby authorized to charge any appropriate fees under 37 C.F.R. § 1.17 that may be required by this paper, and to credit any overpayment, to Deposit Account No. 02-4800. This paper is submitted in duplicate.

Respectfully submitted,

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Date: April 1, 2004

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